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Characterization of an Acetone Detector Based on a Suspended WO$_3$-Gate AlGaN/GaN HEMT Integrated With Microheater

Jianwen Sun, Robert Sokolovskij, Elina Iervolino, Fabio Santagata, Zewen Liu, Pasqualina M. Sarro, Fellow, IEEE, and Guoqi Zhang, Fellow, IEEE

Abstract—A suspended AlGaN/GaN high electron mobility transistor (HEMT) sensor with a tungsten trioxide (WO$_3$) nanofilm modified gate was microfabricated and characterized for ppm-level acetone gas detection. The sensor featured a suspended circular membrane structure and an integrated microheater to select the optimum working temperature. High working temperature (300°C) increased the sensitivity to up to 25.7% and drain current change $i_{DS}$ to 0.31 mA for 1000-ppm acetone in dry air. The transient characteristics of the sensor exhibited stable operation and good repeatability at different temperatures. For 1000-ppm acetone concentration, the measured response and recovery time were reduced from 148 and 656 to 48 and 320 s as the temperature increased from 210°C to 300°C. The sensitivity to 1000-ppm acetone gas was significantly greater than the sensitivity to ethanol, ammonia, and CO gases, showing low cross-sensitivity. These results demonstrate a promising step toward the realization of an acetone sensor based on the suspended AlGaN/GaN HEMTs.

Index Terms—Acetone sensor, AlGaN/GaN, gas sensor, high electron mobility transistor (HEMT), WO$_3$.
Fig. 1. Schematic cross section of the HEMT sensor structure.

have been demonstrated for H₂ [21], CO [22]–[24], NO [25], [26], NO₂ [26]–[28], NH₃ [25], [29], [30], CH₄ [31], H₂S [32], [33], and C₂H₂ [34]. So far, very few results of acetone detection with AlGaN/GaN devices have been reported [35].

As for most of the chemical sensing, the important parameters such as selectivity, sensitivity, and response/recovery time of the gas sensors can be promoted by increasing the surface temperature. External heating element can be used to achieve the required temperature. However, it may not be feasible for some applications. Therefore, integrating a heating unit is an attractive alternative to elevate sensor performance [36].

In this article, we demonstrate the successful sensing of acetone vapor using a suspended WO₃-gate AlGaN/GaN HEMT sensor with an integrated microheater. The transient characteristics of the sensor at various surface temperatures and acetone concentrations under room temperature and in dry air ambient are investigated. The sensor shows a current increase and rapid response to different acetone concentrations. Moreover, the selectivity and reproducibility of the sensor are demonstrated.

II. EXPERIMENT

A. Fabrication

Fig. 1 presents a schematic of the device cross section. The HEMT sensor is fabricated together with the microheater surrounding the source/gate/drain area on a suspended membrane. The contact pads are on a thick silicon frame.

The epitaxial structure was grown on a 2-in silicon <111> wafer using metal-organic chemical vapor deposition. Starting from the substrate, the structure consisted of a 2-μm-thick undoped GaN buffer layer, followed by a 1-nm-thick AlN interlayer, an undoped 25-nm-thick Al₀.₂₆Ga₀.₇₄N barrier layer, and a 3-nm-thick GaN epitaxial cap layer. The fabrication process flow started with a mesa etching using a chlorine/boron chloride (Cl₂/BCl₃) plasma to define the sensor geometry. Then, Ti/Al/Ti/Au (20/110/40/50 nm) metal contacts were e-beam evaporated and patterned by the lift-off technology. A rapid thermal annealing at 870°C for 45 s under N₂ ambient was performed to obtain an ohmic contact. Then, a Ti/Pt (30/200 nm) metal layer as the microheater layer was evaporated and patterned by the lift-off process, followed by a SiO₂ layer as the isolation layer. Then the metal interconnect was formed using an evaporated Ti/Au (20/300 nm) layer stack. A 5-μm-thick SiO₂ layer as hard mask during the DRIE process to etch the silicon substrate and the topside SiO₂ layer as the passivation layer were deposited. The WO₃ (10 nm) layer was then deposited on the gate area of 80 μm × 40 μm by physical vapor deposition (PVD). The silicon substrate is etched away below the active area in the final step, thus forming the membrane and the suspended sensor structure. The main steps of the fabrication processes are shown in Fig. 2. More details can be found in our early work [32].

The microheater has a rectangular geometry around a central area of 230 μm × 290 μm, as shown in Fig. 3(a). Fig. 3(b) shows the SEM images of the AlGaN/GaN HEMTs and the atomic force microscope (AFM) image and profile of the 10-nm WO₃ layer.

B. Characterization

After dicing, the chips were wire-bonded to a ceramic quad flat no-lead (CQFN) package with a size of 4 mm × 4 mm [Fig. 2(c)]. This sensor package is designed to eliminate the effect of gas flow by a perforated lid. The 8-pin QFN testing socket is placed in a gas chamber and electrically connected to a Keithley 2400 source meter. The target gas was injected into the test chamber by a microinjector. The target liquid, for example, acetone and ethanol, injected into the chamber was...
evaporated. After the drain current reached a new saturation, the test chamber was opened and the gas was removed by a micro air pump. The gas sensitivity was designated as 

\[ S(\%) = \frac{\Delta I_{DS}}{I_{DS,\text{air}}} \times 100\% \]

where \( \Delta I_{DS} = I_{DS,\text{acetone}} - I_{DS,\text{air}} \) is the drain current change between acetone and air ambient. The response time \( t_{\text{Res}} \) and recovery time \( t_{\text{Rec}} \) were defined as the time required for the drain current to change/return from 10\% to 90\% of its saturated response value to acetone gas.

### III. Results and Discussion

To extract the membrane temperature, a calibration of the membrane temperatures is necessary. The surface temperature can be measured by infrared radiation (IR) thermal camera (Bruker) or extracted by the resistance change in the microheater at ambient temperature with the four-wire testing method [37]. Fig. 4 shows the measured maximum temperatures and microheating power consumption of the suspended AlGaN/GaN membrane at various applied microheater voltages \( V_H \). For \( V_H = 3.5 \) V and \( V_H = 4 \) V, the maximum gate surface temperatures are calculated to be about 210°C and 300°C. The power consumption of the sensor is about 200 mW when the operating temperature is about 300 °C. To further improve the heating efficiency, a larger size membrane and cyclic heating [36] can be used.

#### A. Response to acetone in Air

Fig. 5 shows the transient performance of the WO3 HEMT sensors at the applied microheater voltage \( V_H = 3.5 \) V in
the gas concentration range from 100 to 1000 ppm. Upon exposure to acetone, the source–drain current increases from the baseline value in dry air. The sensor shows stable operation and good repeatability, both for increasing [Fig.5(a)] and decreasing [Fig.5(b)] gas concentration.

An important sensor parameter is the magnitude of sensing signal variation $\Delta I_{DS}$. Previously reported gas sensors based on AlGaN/GaN Schottky diodes show very high sensitivities, in the order of 1000% at ppm-level gas concentrations. However, the current change was in nA–μA range, due to the low baseline signal values. Low $\Delta I_{DS}$ will result in higher noise susceptibility of the sensor and higher limit of detection.

Fig. 6 shows the drain–source current change and sensitivity as a function of acetone concentration for $V_{DS} = 5\, V$, $V_H = 3.5\, V$ (210 °C), and $V_H = 4\, V$ (300 °C). It is obvious that the response increased at a higher temperature. In this work, for 1000-ppm acetone concentration, the measured $\Delta I_{DS}$ and sensitivity showed an almost twofold increase, from 0.18 mA (12%) at $V_H = 3.5\, V$ to 0.31 mA (25.7%) at $V_H = 4\, V$, while at 100 ppm $\Delta I_{DS} = 0.16\, mA$, which is larger than the reported value of $\Delta I \sim 12\, \mu A$ at 100-ppm acetone for a Schottky-type sensor [35], [38]. Figs. 5 and 6 show that lower concentration of acetone could be expected due to the large drain current change.

The drain current change and sensitivity to 1000-ppm acetone at different drain–source voltage are shown in Fig. 7. The current variation and sensitivity increase when $V_{DS}$ increases from 0 to 5 V. However, the current change and sensitivity decrease with an increase in $V_{DS}$, due to the sensor working in the saturation range. The optimized $V_{DS}$ of this sensor is around 5 V.
Fig. 9. Sensitivity to 1000-ppm acetone at different microheater voltages (temperature).

The repeatability of the sensor measured at \(V_H = 3\) V (135 °C), \(V_H = 3.5\) V (210 °C), and \(V_H = 4\) V (300 °C) is shown in Fig. 8. The drain current response to acetone gas when the acetone concentration is swept back and forth from 0 to 1000 ppm is reported.

The effect of the working temperature, known to have a great influence on the sensitivity of the gas sensor, was studied as well. Six repetitive cycles of sensor exposure to 1000-ppm acetone at various working temperatures regulated by the integrated microheater voltage are shown in Fig. 8. The sensitivity as a function of the microheater voltage is plotted in Fig. 9. The sensitivity of the sensor exposed to 1000-ppm acetone at \(V_H = 3\) V (135 °C), \(V_H = 3.5\) V (210 °C), and \(V_H = 4\) V (300 °C) is 0.8%, 12%, and 25.7%, respectively.

![Fig. 10](image)

(a) Response time and (b) recovery time versus acetone concentration at \(V_H = 3.5\) V (210 °C) and \(V_H = 4\) V (300 °C).

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**TABLE I**

<table>
<thead>
<tr>
<th>Acetone conc. (ppm)</th>
<th>(t_{res}) (s)</th>
<th>(t_{rec}) (s)</th>
</tr>
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<tbody>
<tr>
<td>100</td>
<td>436</td>
<td>255</td>
</tr>
<tr>
<td>200</td>
<td>230</td>
<td>80</td>
</tr>
<tr>
<td>400</td>
<td>166</td>
<td>61</td>
</tr>
<tr>
<td>600</td>
<td>146</td>
<td>44</td>
</tr>
<tr>
<td>800</td>
<td>137</td>
<td>579</td>
</tr>
<tr>
<td>1000</td>
<td>148</td>
<td>48</td>
</tr>
</tbody>
</table>

\(t_{res}\) = response time; \(t_{rec}\) = recovery time.

Fig. 10 characterizes \(t_{res}\) and \(t_{rec}\) as a function of acetone concentration at the applied microheater voltages. The transient response times decreased with increasing gas concentration for \(V_H = 3.5\) V (210 °C) and \(V_H = 4\) V (300 °C), while the recovery times increased with increasing gas concentration. From a concentration of 400 ppm, \(t_{res}\) is stable. The response time and recovery time at different temperatures are shown in Table I. At 1000-ppm acetone concentration, \(t_{res}\) (\(t_{rec}\)) reduced from 148 (656) s at \(V_H = 3.5\) V (210 °C) to 48 (320) s at \(V_H = 4\) V (300 °C). At the concentration of 100 ppm, \(t_{res}\) (\(t_{rec}\)) also decreased from 436 (255) s to 252 (108) s with increasing temperature. The shorter response (recovery) time is attributed to faster gas adsorption and desorption rate at the gate surface under higher temperature.

Another important characteristic of the sensor is selectivity. Fig. 11 presents the acetone selective performance of the HEMT sensor to other typical interfering gases such as ethanol, ammonia, and CO at \(V_H = 4\) V. The sensor sensitivity to 1000-ppm acetone is 25.7% and the sensitivity to ethanol, ammonia, and CO is as low as 16.9%, 3.2%, and 2.6%, respectively. It is evident that the HEMT gas sensor exhibits good selectivity toward acetone. The humidity effect at different temperatures is shown in Fig. 12. The effect of the relative humidity on \(I_{DS}\) becomes insignificant with increasing temperature.

**B. Sensing Mechanism of WO3/AlGaN/GaN Sensor**

Previously, it was found that the gas molecules containing oxygen, upon adsorption on the surface of the catalytic metals

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**AUTHOR:** SUN et al.

**Title:** CHARACTERIZATION OF AN ACETONE DETECTOR

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</table>

\(t_{res}\) = response time; \(t_{rec}\) = recovery time.

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**Fig. 11.** Gas sensing response to 1000 ppm of acetone, ethanol, ammonia, and CO at \(V_H = 4\) V.
oxygen adsorption on the WO3 surface traps electron from the in Fig. 13, because of the presence of oxygen in the air, 
[39], [40]. When the sensor is in contact with air as shown (e.g., Pt, Pd, or Ag), dissociate and release electrons [30], [39], [40]. When the sensor is in contact with air as shown in Fig. 13, because of the presence of oxygen in the air, oxygen adsorption on the WO3 surface traps electron from the conduction band of the semiconductor to form oxygen species $(O_2^−, O^−, or O^{2−})$ [35], [40]. In this ionosorption process, this doubly charged adsorbed oxygen $O^{2−}$ is not stable when the doubly charged oxygen ions do not react immediately or are trapped by oxygen vacancies

\[
\begin{align*}
O_2(gas) \Rightarrow O_2(ads) & \quad (1) \\
O_2(ads) + e^- \Rightarrow O_2^-(ads) & \quad (2) \\
O_2^-(ads) + e^- \Rightarrow 2O^-(ads) & \quad (3) \\
O^-(ads) + e^- \Rightarrow O^{2-}(ads). & \quad (4)
\end{align*}
\]

Such oxygen ions will act as electron trap on the sensing surface. When the temperature of the sensing area is above 150 °C, $O^−$ dominates during the ionosorption process. The reaction rate of $O^−$ is greater than $O^{2−}$. Accordingly, once the sensor is exposed to acetone gas, the acetone molecules react with the adsorbed oxygen ions $O^−$, then produce $CO_2$ and $H_2O$, and release electrons following (5) [10], [41], [42]. Releasing electrons in the conduction band leads to the bending of the band toward lower energy and move to 2-DEG channel, which increases the drain current after exposure to acetone gas

\[
\text{CH}_3\text{COCH}_3(gas) + 8O^- \rightarrow 3\text{CO}_2 + 3\text{H}_2\text{O} + 8e^-.
\]

In addition, the surface states would be altered by the polar acetone molecules, which would manipulate the 2-DEG concentration. Therefore, the surface potential of the WO3 and AlGaN are changed, resulting in the variation in the drain current of the HEMT device. The changed surface potential can mathematically be represented by the Helmholtz model

\[
\Delta V = \frac{N_S p (\cos \theta)}{\epsilon \epsilon_0}
\]

where $p$ is the dipole moment, $N_S$ is the dipole density per unit area, $\theta$ is the angle between the dipole and the normal surface, $\epsilon$ is the relative permittivity of the material, and $\epsilon_0$ is the permittivity of free space. The surface potential is majorly affected by the value of $p/\epsilon$ of the polar molecules. Compared with other gases such as ethanol and ammonia, acetone is one of the most polar molecules. Consequently, the sensitivity of the device to acetone is larger than for other gases.

IV. CONCLUSION

The suspended AlGaN/GaN HEMT sensors with a tungsten trioxide (WO3) nanofilm modified gate were developed for ppm-level acetone gas detection. The temperature of the sensor can be adjusted by the integrated microheater, and the membrane structure was designed for operation at high temperature and low power. At 300 °C, a drain current change $\Delta I_{DS}$ of 0.31 mA and a high sensitivity of 25.7% for 1000-ppm acetone were observed. Transient measurements indicated stable operation and good repeatability at different temperatures. For 1000-ppm acetone concentration, $I_{Rec}$ reduced from 147 (656) s at $V_H = 3.5$ V (210 °C) to 48 (319) s at $V_H = 4$ V (300 °C). Moreover, the response to 1000-ppm acetone gas was significantly larger than for ethanol, ammonia, and CO gases at the same 1000-ppm concentration. These performances reveal that GaN-based HEMT sensors are a promising approach for gas sensing in industrial and medical applications.

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